

10/594635

New PCT National Phase Application
Docket No. 2691-000050/US

IAP5 Rec'd PCT/PTO 28 SEP 2006

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant(s): Yoshiharu OHTA et al.
Int'l App. No.: PCT/JP2005/005766
Application No.: **NEW APPLICATION**
Filed: September 28, 2006
For: SEMICONDUCTOR POLISHING COMPOSITION
(as amended)

PRELIMINARY AMENDMENT

Customer Service Window
Randolph Building
401 Dulany Street
Alexandria, VA 22314
Mail Stop PCT

September 28, 2006

Sir:

The following preliminary amendments and remarks are respectfully submitted in connection with the above-identified application. Prior to examination of the present application, please consider the following:

Amendments to the Title begin on page 2 of this Preliminary Amendment.

Amendments to the Abstract begin on page 3 of this Preliminary Amendment.

Amendments to the Specification begin on page 4 of this Preliminary Amendment.

Amendments to the Claims begin on page 5 of this Preliminary Amendment.

| | Claims remaining after Amendment | | Highest number previously paid for | | Present extra |
|-------------|-------------------------------------|---|---------------------------------------|---|---------------|
| Total | 12 | - | 20 | = | 0 |
| Independent | 1 | - | 3 | = | 0 |